

WaferBOND® CR-200

Temporary Bonding Material

WaferBOND® CR-200 temporary bonding material enables back-end-of-line processing of ultrathin wafers with standard semiconductor equipment.

PROCESSING

Best known methods

	20-µm process	
Coat		
Spin speed	1200 rpm	
Acceleration	3000 rpm/s	
Time	30 s	
Bake		
Bake 1	120°C, 3 min	
Bake 2	180°C, 4 min	
Bond		
Temperature	180°C	
Force	3500 N	
Time	2 min	
Vacuum	≤ 5 mbar	

Storage Conditions

Store at room temperature (16° to 26°C)

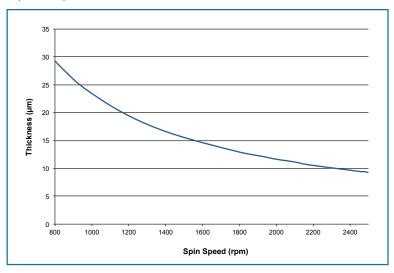
Debonding Process (Two-Bath Process)

- Bath 1: Submerge in WaferBOND® Remover material at 110° to 130°C for 1 to 4 hours, or until debonded.
- Bath 2: Clean up with WaferBOND® Remover material at 70° to 110°C for 15 minutes to 1 hour. Mild circulation is recommended.
- Rinse: Isopropanol (IPA)
- Dry

BENEFITS

- Process ultrathin wafers using standard lithographic, passivation, and metallization techniques and tooling
- Create interconnects before or after thinning
- Preserve delicate structures or III-V devices

Spin Speed Curve



Resistance to Process Chemicals

Chemistry	Bath Temp.	Time	
Acetone	25°C	25 min	
NMP	85°C	60 min	
6N HCI	60°C	30 min	
15% H ₂ O ₂	60°C	40 min	
30% NH₄OH	25°C	30 min	
10% KI in H ₂ O	25°C	20 min	
Ethanol	25°C	5 min	
Methanol	25°C	5 min	
Isopropanol	25°C	5 min	
Cyclohexanone	25°C	5 min	
Ethyl Lactate	25°C	5 min	
PGMEA	25°C	5 min	
PGME	25°C	5 min	
30% HCI	25°C	90 min	
70% HNO ₃	25°C	60 min	
Note: An HMDS pretreatment is recommended for the following exposure recipes:			
0.26N TMAH	60°C	30 min	
30% KOH	85°C	60 min	

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